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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/766,896	01/30/2004	Makoto Terui	030712-23	5698
22204 7	590 11/30/2005		EXAM	INER
NIXON PEABODY, LLP 401 9TH STREET, NW		PAREKH, NITIN		
SUITE 900	3131, 14 44		ART UNIT	PAPER NUMBER
WASHINGTO	N, DC 20004-2128		2811	

DATE MAILED: 11/30/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

			/			
	Application No.	Applicant(s)				
Office Action Summany	10/766,896	TERUI, MAKOTO				
Office Action Summary	Examiner	Art Unit				
	Nitin Parekh	2811				
The MAILING DATE of this communication appeared for Reply	pears on the cover sheet	with the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING D - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUI 136(a). In no event, however, may will apply and will expire SIX (6) M e, cause the application to become	NICATION. a reply be timely filed ONTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).				
Status						
1)⊠ Responsive to communication(s) filed on 06 S	September 2005.					
·= · · · · · ·	s action is non-final.					
3) Since this application is in condition for allowa	nce except for formal m	atters, prosecution as to the merits is				
closed in accordance with the practice under t	Ex parte Quayle, 1935 C	.D. 11, 453 O.G. 213.				
Disposition of Claims						
4) Claim(s) 4-12,14 and 17-22 is/are pending in t	the application.					
	4a) Of the above claim(s) <u>17-19</u> is/are withdrawn from consideration.					
5) Claim(s) 22 is/are allowed.						
6)⊠ Claim(s) <u>4-12,14,20 and 21</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	or election requirement.					
Application Papers						
9)☐ The specification is objected to by the Examine	er.					
10)⊠ The drawing(s) filed on 30 January 2004 is/are	: a)⊠ accepted or b)□	objected to by the Examiner.				
Applicant may not request that any objection to the		, ,				
Replacement drawing sheet(s) including the correct						
11)☐ The oath or declaration is objected to by the E	kaminer. Note the attach	ed Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign a)⊠ All b)□ Some * c)□ None of:	priority under 35 U.S.C	. § 119(a)-(d) or (f).				
1. Certified copies of the priority document						
2. Certified copies of the priority document						
3. Copies of the certified copies of the prio		en received in this National Stage				
application from the International Burea	• • • • • • • • • • • • • • • • • • • •	ot magained				
* See the attached detailed Office action for a list	or the centiled copies no	ot received.				
Attachment(s)						
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) ∐ Interviev Paper N	v Summary (PTO-413) o(s)/Mail Date				
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date		f Informal Patent Application (PTO-152)				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.

2. Claim 20 is rejected under 35 U.S.C. 102(a) as being anticipated by Kishimoto et al. (US Pat. 6603210).

Regarding claim 20, Kishimoto et al. disclose a multichip module (MCM- see Fig. 1 and 5a-5c) comprising a semiconductor chip and a plurality of passive elements/chips (see 6 in Fig. 5a-5c)

- a substrate (1/2/3 in Fig. 1)
- an insulating resin layer (9 in Fig. 1) formed on the substrate
- an inductor (see 6 in Fig. 1 and 5a-5c; Col. 5, line 45) formed/positioned in the insulating layer by a first metal terminal/wire terminal (not numerically referenced in Fig. 1; see edge metal connections of the circuit element 6 in Fig. 5a-5c; col. 10, line 7)
- a capacitor (see 6 in Fig. 1 and 5a-5c; Col. 5, line 45) formed/positioned in the insulating layer by a second metal terminal/wire (not numerically referenced in Fig. 1; see edge metal connections of other circuit element 6 in Fig. 5a-5c; Col. 10, line 7), wherein the capacitor is isolated from the inductor (see Fig. 5a)

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- a protective film (4 in Fig. 1) formed on the insulating layer, wherein the protective film has first and second openings for exposing the inductor and capacitor respectively (see openings in 4 having conductive joint 8 in Fig. 1)

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- first and second wiring patterns respectively (see 3a in Fig. 1) formed within the
 first and second openings; and
- the first and second wiring patterns formed for connecting to an external source and other external source respectively (see 12 in Fig. 1 and 5b)

(Fig. 1 and 5a-5c; Col. 4, line 60- Col. 7, line 45; Col. 8, line 50- Col. 10, line 55).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 4-12, 14 and 21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kishimoto et al. (US Pat. 6603210). in view of Maeda et al. (US Pat. 6582991), Lin et al. (US Pat. 2002/0122244) and Panella et al. (US Pat. 6853559).

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Regarding claims 4-12, 14 and 21, Kishimoto et al. teach the entire structure as applied to claim 20 above, except the passive elements being of different specifications or being formed on the substrate by metal wires.

Maeda et al. teach a multichip module (MCM) having IC chip elements/components wherein the chip components include a variety of active and passive components (300 and 200 respectively in Fig. 2) wherein the passive component types include conventional resistor, capacitor, etc. each component having respective specifications (resistance, capacitance, inductance, quality factor, etc.), values and dimensions to provide the desired application requirements (Col. 13, lines 20-35). Furthermore, the elements/components include those of the same or different types (see Fig. 18, 19, etc.) as per application requirements (Col. 28, line 33- Col 30, line 15)

Lin et al. teach a MCM having a variety of conventional passive devices/chip components (644 in Fig. 11A) including capacitor, inductor, etc. wherein the inductor and the capacitor are formed on a substrate by spirally disposed metal pattern/wires and conventional capacitor configuration including parallel wiring layers/electrode layers respectively (see 642a in Fig. 11A and Fig. 10B respectively; section 0072). Lin et al. further teach the chip components/passive devices being formed/diced from a wafer using a conventional wafer scale processing (sections 0006-00010).

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Kishimoto et al. further teach the terminals of the passive elements/chips being connected by second/external electrodes covered by an insulating/protective resin layer (see 12 and 11 respectively in Fig. 1).

Panella et al. teach an IC system integration comprising active/passive IC chips/components including resistor, capacitor, etc. wherein the chips/components include those having high/low frequency specifications, the system configuration further include the components being configured/divided into groups including high and low frequency specifications to provide the desired power/signal and performance requirements and improved electromagnetic interference (EMI) protection and thermal management (see col. 2, 5, 9, 22-28; Fig. 1-19).

Furthermore, the determination of parameters such as number of passive components, types, grouping according to the specifications including frequency characteristics and other performance parameters in a multichip packaging and interconnection technology art is a subject of routine experimentation and optimization to achieve the desired application requirements, module performance and reliability.

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate the plurality of passive elements having different specifications, being formed on the substrate by metal wires and being divided into a plurality of groups having mutually different specifications or groups including high and low frequency specifications as taught by Maeda et al., Lin et al. and Panella et al. so

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that the desired device integration, performance and reliability can be achieved in Kishimoto et al's MCM.

Allowable Subject Matter

5. Claim 22 is allowed.

Reasons for Allowance

6. The following is an examiner's statement of reasons for allowance:

The references of record do not teach either singularly or in combination at least the limitations "a passive element chip within the insulating film and being formed on the first substrate, and a semiconductor chip within the insulating film and being formed on the first substrate" and "wherein the passive element chip comprises a second substrate different from the first substrate; an insulating layer formed on the second substrate; an inductor formed in the insulating layer by a first metal wire; a capacitor formed in the insulating layer by a second metal wire, with the capacitor being isolated from the inductor" in a highly integrated module having active and passive components within an insulating film on a substrate.

Response to Arguments

7. Applicant's arguments with respect to claims 4-12, 14, 20 and 21 have been considered but are most in view of the new ground(s) of rejection.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nitin Parekh whose telephone number is 571-272-1663. The examiner can normally be reached on 09:00AM-05:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAN or Public PAG. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAG system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

NP

NITIN PAREKH

Nti Parell

11-26-05

PRIMARY EXAMINER

TECHNOLOGY CENTER 2800